

Amendment to the Claims:

This listing of claims will replace all prior versions and listings of claims in the application. Please enter new claims 34-40.

Listing of Claims:

1. – 12. (Canceled)
13. (Previously presented) A method comprising:
 - depositing a first metallic film and a second metallic film on a substrate;
 - depositing a layer of photoresist on at least the first metallic film;
 - patterning the photoresist such that a desired portion of the first metallic film is masked and an undesired portion of the first metallic film is exposed;
 - selecting two or more chelating agents based upon the metals contained in the first metallic film; and
 - using the two or more chelating agents to remove the undesired portion of the first metallic film, wherein the two or more chelating agents do not impair the second metallic film.
14. (Previously presented) The method of claim 13 further comprising:
 - selecting a media in which to employ the two or more chelating agents based upon the metals contained in the first metallic film.

15. (canceled)

16. (Previously presented) The method of claim 13 wherein the two or more chelating agents are employed in a solution at a concentration ranging from approximately 0.5 – 5 moles/liter, for each chelating agent.

17. (Previously presented) The method of claim 14 wherein the two or more chelating agents are employed in a solution selected from the group consisting of an acidic solution, a basic solution, a solvent solution, and a de-ionized water solution.

18. (Previously presented) A method comprising:

depositing a first metallic film and a second metallic film on a substrate;
depositing a layer of photoresist on at least the first metallic film;
patterning the photoresist such that a desired portion of the first metallic film is masked and an undesired portion of the first metallic film is exposed;
selecting a media in which to employ two or more chelating agents based upon the metals contained in the first metallic film; and
employing the two or more chelating agents to remove the undesired portion of the first metallic film, wherein the two or more chelating agents do not impair the second metallic film.

19. (Canceled)

20. (Previously presented) The method of claim 18 wherein the media is a liquid media selected from the group consisting of an aqueous acid media with oxidant, an aqueous acid media without oxidant, an aqueous basic media without oxidant, and a solvent media without oxidant having a pH of approximately seven.

21. (Previously presented) The method of claim 18 wherein the two or more chelating agents are employed in a solution at a concentration ranging from approximately 0.5 – 5 moles/liter, for each chelating agent.

22. (Previously presented) The method of claim 13 wherein the two or more chelating agents are used in proportion to a proportion of metals of the first metallic film.

23. (Previously presented) The method of claim 13 wherein the two or more chelating agents are specifically tailored to bind with metals in the first metallic film.

24. (Previously presented) The method of claim 18 wherein the two or more chelating agents are used in proportion to a proportion of metals of the first metallic film.

25. (Previously presented) The method of claim 18 wherein the two or more chelating agents are specifically tailored to bind with metals in the first metallic film.

26. – 31. (canceled)

32. (Previously presented) The method of claim 13 wherein said first metallic film is an alloy comprised of at least two different metals.

33. (Previously presented) The method of claim 18 wherein said first metallic film is an alloy comprised of at least two different metals.

34. (New) A method comprising:

depositing a first metallic film and a second metallic film on a substrate;
masking the first metallic film such that a desired portion of the first metallic film is masked and an undesired portion of the first metallic film is exposed;
selecting two or more chelating agents based upon the metals contained in the first metallic film; and
using the two or more chelating agents to remove the undesired portion of the first metallic film, wherein the two or more chelating agents do not impair the second metallic film.

35. (New) The method of claim 34 further comprising:

selecting a media in which to employ the two or more chelating agents based upon the metals contained in the first metallic film.

36. (New) The method of claim 34 wherein the two or more chelating agents are employed in a solution at a concentration ranging from approximately 0.5 – 5 moles/liter, for each chelating agent.

37. (New) The method of claim 35 wherein the two or more chelating agents are employed in a solution selected from the group consisting of an acidic solution, a basic solution, a solvent solution, and a de-ionized water solution.

38. (New) The method of claim 34 wherein the two or more chelating agents are used in proportion to a proportion of metals of the first metallic film.

39. (New) The method of claim 34 wherein the two or more chelating agents are specifically tailored to bind with metals in the first metallic film.

40. (New) The method of claim 34 wherein said first metallic film is an alloy comprised of at least two different metals.